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## HIGHLIGHTS

investigated.

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• H<sub>2</sub> adsorption on MoS<sub>2</sub> and WS<sub>2</sub> was

First-principles van der Waals functional (vdW-DF) method was applied for the considered systems.
The H<sub>2</sub> molecule is physisorbed on the surface of the monolayer MoS<sub>2</sub> and WS<sub>2</sub> with adsorption energies of – 131.61 and – 169.44 meV.
Adsorption of two H<sub>2</sub> molecules on one and both sides of the monolayer MoS<sub>2</sub> and WS<sub>2</sub> was examined.
We calculated the binding energy between the H<sub>2</sub> molecule and the substrate (MoS<sub>2</sub> and WS<sub>2</sub>) under

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# G R A P H I C A L A B S T R A C T

Hydrogen molecule is physisorbed on the surface of the monolayer  $MoS_2$  and  $WS_2$  and the binding energy between the  $H_2$  molecule and the substrate is enhanced by axial strain.



## ABSTRACT

In this work, we report a theoretical study on the adsorption of molecular hydrogen  $(H_2)$  on monolayer molybdenum disulfide (MoS<sub>2</sub>) and tungsten disulfide (WS<sub>2</sub>) using a first-principles van der Waals functional (vdW-DF) method. Our calculations show that the most favorable configuration for the adsorption of a H<sub>2</sub> molecule on monolayer MoS<sub>2</sub> is similar to that for the monolayer WS<sub>2</sub> surface. The H<sub>2</sub> molecule is physisorbed on the surface of the monolayers MoS<sub>2</sub> and WS<sub>2</sub> with adsorption energies of - 131.61 and - 169.44 meV, respectively. Analysis of the electronic structures and charge confirmed that no significant hybridization between the respective orbitals occurs, and quantitative analysis revealed that a small interaction was obtained in terms of binding energies. Furthermore, adsorption of two H<sub>2</sub> molecules on one and both sides of the monolayer MoS<sub>2</sub> and WS<sub>2</sub> was examined. The obtained results indicated that, with the adsorption of the second H<sub>2</sub> molecule on one- and both-side of WS<sub>2</sub>, the binding energies were decreased to - 155.2 and - 153.6 meV, respectively. However, the values for adsorption of the second H<sub>2</sub> on monolayer MoS<sub>2</sub> remained nearly constant compared to the adsorption of the first H<sub>2</sub> molecule. In addition, we calculated the binding energy between the  $H_2$  molecule and the substrate  $(MoS_2 \text{ and } WS_2)$  under axial strain of -10% to 10%, which revealed that the binding energy between the H<sub>2</sub> molecule and the substrate was enhanced by axial strain. Our results also indicated that applying compression to monolayer WS<sub>2</sub> yields higher reactivity with the hydrogen molecule than applying compression to monolayer MoS<sub>2</sub>.

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## 1. Introduction

Hydrogen is a favorable alternative fuel that is widely considered as an economical, nonpolluting, and renewable source of energy that contains much more chemical energy per mass than any petroleum fuel [1]. Hydrogen can be used as a clean fuel for vehicles, personal electronics, and other portable power applications [2]. Some critical challenges for storage materials include the need for chemical stability [3], a large surface area, hydrogen storage at ambient temperature and pressure, reversibility, and fast kinetics [4]. Many different materials have been considered as attractive candidates for safe and economically feasible hydrogen storage media, such as carbon-based materials [5–7], metal or chemical hydrides [8], and microporous polymers [9]. However, no material that can meet all the requirements listed above has been developed.

Two-dimensional (2D) materials have attracted much attention, primarily because of their interesting physical properties, which are strikingly different from those of their three-dimensional (3D) (bulk) counterparts. Graphene is the most famous member of the 2D material family, but nanosheets of transition metal disulfides (TMDs) consisting of a single to a few layers, such as molybdenum disulfide (MoS<sub>2</sub>) and tungsten disulfide (WS<sub>2</sub>), have recently attracted widespread attention as an alternative to graphitic carbon due to their high energy capacity. For example, the energy capacity of monolayer MoS<sub>2</sub> is approximately 1200 mAh/g [10–13], which is much higher than that of commercial graphite (372 mAh/g) [14] and graphene nanosheets (600-900 mAh/g) [15-17]. Transition metal disulfides have been widely used in numerous applications, such as hydrodesulfurization catalysts, photovoltaic cells, photocatalysts, nanotribology, lithium batteries, and dry lubrication, due to their distinctive electronic, optical, and catalytic properties [18,19]. The structures of MoS<sub>2</sub> and WS<sub>2</sub> are analogous to that of graphite and comprise triple atomic layers: a Mo or W layer in the trigonal prismatic coordination sandwiched between two layers of pyramidal S atoms. The triple layers are stacked and held together by weak van der Waals (vdW) interactions [20]. Monolayer MoS<sub>2</sub> and WS<sub>2</sub> are direct gap semiconductors with a bandgap of 1.8 eV and display good thermal stability [21,22]. MoS<sub>2</sub> and WS<sub>2</sub> nanosheets with one or a few layers were recently synthesized experimentally using scotch-tape or lithium-based intercalation methods shortly after the theoretical predictions [23–25]. The separation between the MoS<sub>2</sub> and WS<sub>2</sub> layers was reported to be in the range of 0.62-0.70 nm [23,26]. Theoretical studies of monolayer MoS<sub>2</sub> and WS<sub>2</sub> as substrates based on density functional theory (DFT) have recently been conducted [20-22,27]. In 2012, Koh et al. [4] investigated hydrogen adsorption on a MoS<sub>2</sub> monolayer based on the DFT method, which revealed that the conductivity of monolayer MoS<sub>2</sub> is greatly enhanced by the adsorption of hydrogen.

In this work, we systematically studied the adsorption properties of hydrogen molecules on monolayer MoS<sub>2</sub> and WS<sub>2</sub> using DFT calculations. We also calculated the adsorption energies of two hydrogen molecules on the MoS<sub>2</sub> and WS<sub>2</sub> substrates. We investigated individually the dispersion of hydrogen molecules that approach either side of a monolayer MoS<sub>2</sub> or WS<sub>2</sub> substrate. This is the first study to use DFT calculations to address the effects of the adsorbed hydrogen molecule on the structural and electronic properties of the WS<sub>2</sub> surface. The investigation of hydrogen molecules on monolayer MoS<sub>2</sub> substrates has seldom been reported. Finally, we introduced two different types of strain in the substrates to improve the binding energy in the systems under consideration.

#### 2. Computational methods

Our calculations of hydrogen adsorption on monolayer  $MoS_2$ and  $WS_2$  substrates were performed within the framework of a *first-principles* DFT method implemented with the Spanish Initiative for Electronic Simulations with Thousands of Atoms (SIESTA) software package [28–31]. We adopted the generalized gradient approximation (GGA) to treat the exchange and correlation potential with the Perdew–Burke–Ernzerhof (PBE) functional [32]. In addition, it is important to consider nonlocal corrections that are responsible for vdW interactions.

Due to the limitation of conventional local DFT calculations in presenting the nonlocal dispersion correlation, we also used a fully nonlocal energy functional (vdW-DF) based on Grimme at the GGA level of theory, in which the PBE exchange functional is favorable for calculating vdW interactions [33,34]. All calculations were performed with a double-t basis set of localized numerical atomic orbitals, including polarization functions (DZP), with an energy shift of 50 meV and a split norm of 0.15. The mesh cutoff, an energy that corresponds to the grid spacing, was chosen to equal 150 Ry to represent the charge density. A  $4 \times 4 \times 1$  Monkhorst-Pack grid for k-point sampling of the Brillouin zone was set, and the atomic positions were relaxed until the residual forces on each atom were less than 0.01 eV/Å. The supercell of monolayer MoS<sub>2</sub> or WS<sub>2</sub> consisted of 18 S atoms and 9 Mo/W atoms, and a periodic boundary condition was applied to the supercell. A vacuum width of 18 Å was constructed to eliminate interactions between adjacent images of the supercell. To calculate the interaction between a H<sub>2</sub> molecule and substrate, the basis set superposition error (BSSE) needs to be included in the binding energy calculations for the complexes under consideration. For this propose the counterpoise method using 'ghost' atoms was used according to the following equation:

$$E_b = E_{(TMD-H2)} - E_{(TMD_{phost}-H2)} - E_{(TMD-H2_{phost})}$$
(1)

where  $E_{(TMD-H2)}$  is the total energy of the MoS<sub>2</sub> or WS<sub>2</sub> substrate interacting with the H<sub>2</sub> molecule. The 'ghost' TMD/H2 corresponds to additional basis wave functions centered at the position of the H<sub>2</sub> molecule or the substrate, but without any atomic potential.

# 3. Results and discussion

## 3.1. Structure optimization and geometry of pristine MoS<sub>2</sub>

To investigate the adsorption properties of a hydrogen molecule on monolayer MoS<sub>2</sub>, we first optimized the geometric structure of the substrate. The optimized structures and geometric parameters, which comprised the Mo–S bond length ( $d_{M-S}$ ), Mo– Mo distance ( $d_{M-M}$ ), and S–S distance ( $d_{S-S}$ ) of monolayer MoS<sub>2</sub>, are illustrated in Fig. 1. The calculated  $d_{M-M}$ ,  $d_{M-S}$ , and  $d_{S-S}$  of the substrate were determined to be approximately 3.11, 2.36, and 3.11 Å, respectively. Density of states (DOS) analyses were performed and revealed (Fig. 2) that the pristine MoS<sub>2</sub> may be a semiconductor with a VBM (valence-band maximum)/CBM (conduction-band minimum) energy gap ( $E_g$ ) of 2.58 eV, which is in agreement with previous reports [1]. The net charge transfer was also calculated by Mulliken population charge analysis and indicated that approximately 1.17 electrons charges are transferred from the molybdenum to the sulfur atom.

## 3.2. Hydrogen molecule adsorption on pristine $MoS_2$

To identify the most favorable adsorption configurations, different possible initial configurations were considered, including positioning of the H<sub>2</sub> molecule perpendicular and parallel to the MoS<sub>2</sub> surface on the top, bridge and hollow sites. The top, bridge and hollow sites are directly above the Mo and S atoms, S–S bond, and sulfur trigonal rings of MoS<sub>2</sub>, respectively. Fig. 1(b) presents a schematic representation of the different possible adsorption Download English Version:

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